

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	76	(C4F6 or "C.sub.4 F.sub.6) same (argon or Ar) same (nitrogen or N2 or "N.sub.2")	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 15:37
L2	60	1 and @ay<="2003"	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 14:16
L3	44	(C4F6 or "C.sub.4 F.sub.6" or hexa\$1fluoro\$1butane) same (argon or Ar) same (nitrogen or N2 or "N.sub.2")	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 15:51
L4	4365	(etch\$3 adj rate) with (resist or photo\$1resist or photo\$1sensitive)	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 15:50
L5	6	4 same (C4F6 or "C.sub.4 F.sub.6")	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 15:39
L6	58	4 and (C4F6 or "C.sub.4 F.sub.6")	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 15:39
L7	52	6 not 5	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 15:39
L8	6818	(selective or selectivity) near4 (resist or photo\$1resist or photo\$1sensitive)	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 15:50
L9	94	8 and (C4F6 or "C.sub.4 F.sub.6" or hexa\$1fluoro\$1butane)	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 15:59
L10	52	9 not 7	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 15:51
L11	47	10 and @ay<="2003"	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 15:51
L12	1085	8 and (anti\$1reflective or ARC! or BARC or DARC)	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 16:00
L13	659	12 and (Uv or ultra\$1violet or ("193" adj nm))	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 17:36
L14	479	13 and (passivate or passivating or passivation or polymer)	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 16:04
L15	420	14 and @ay<="2003"	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 16:01

L16	409	15 not (10 or 7)	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 16:01
L17	280	16 and plasma	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 16:02
L18	280	17 and (etch or etching)	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 16:02
L19	594	12 and (Uv or ultra\$1violet)	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 16:04
L20	529	19 and @ay<="2003"	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 16:04
L21	363	20 and plasma	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 16:04
L22	271	21 and (passivate or passivating or passivation or polymer)	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 16:04
L23	34	13 and (acrylic with (resist or photo\$1resist or photo\$1sensitive))	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 18:03
L24	14	(anti\$1reflective or Arc or BARC or DARC) with (C4F6 or "C.sub.4 F. sub.6")	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 18:56
L25	220	438/708.CCLS.	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 18:56
L26	182	438/709.CCLS.	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 18:56
L27	316	438/717.CCLS.	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 18:57
L28	875	438/725.CCLS.	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 18:57
L29	226	438/736.CCLS.	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/12/01 18:59
L30	36	Fu-Qiang.in.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/01 18:59

L32	1	Jeong-James.in.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/01 18:59
L33	36	30 or 32	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/01 19:00